Special Issue

Plasma Medicine Technologies: Volume II

Message from the Guest Editors

The objective of this Special Issue is to present some research underlying new therapeutic methods useful in medicine, dentistry, sterilization, and, in the current scenario, challenges and perspectives in biomedical sciences. This issue will focus on basic studies on the characterization of bioplasma sources applicable to living cells, especially to the human body, and fundamental research on mutual intreactions between the bioplasma and organic–inorganic, liquids and bio- or nanomaterials. The knowledge that has arisen from studies in the plasma medicine area may translate into new innovations to treat patients in daily clinics.

Guest Editors

Prof. Dr. Nagendra Kumar Kaushik

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Deadline for manuscript submissions

closed (30 November 2022)



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Message from the Editor-in-Chief

As the world of science becomes ever more specialized, researchers may lose themselves in the deep forest of the ever increasing number of subfields being created. This open access journal Applied Sciences has been started to link these subfields, so researchers can cut through the forest and see the surrounding, or quite distant fields and subfields to help develop his/her own research even further with the aid of this multi-dimensional network.

Editor-in-Chief

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